

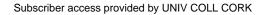
UCC Library and UCC researchers have made this item openly available. Please let us know how this has helped you. Thanks!

| Title | Three-dimensional self-assembled columnar arrays of AlInP quantum wires for polarized micron-sized amber light emitting diodes | |
|--------------------------------|--|--|
| Author(s) | Pescaglini, Andrea; Gocalińska, Agnieszka M.; Bogusevschi, Silviu; Moroni, Stefano T.; Juska, Gediminas; Mura, Enrica E.; Justice, John; Corbett, Brian M.; O'Reilly, Eoin P.; Pelucchi, Emanuele | |
| Publication date | 2018-01-20 | |
| Original citation | Pescaglini, A., Gocalinska, A. M., Bogusevschi, S., Moroni, S. T., Juska, G., Mura, E. E., Justice, J., Corbet, B., O'Reilly, E. and Pelucchi, E. (2018) 'Three-dimensional Self-assembled Columnar Arrays of AlInP Quantum Wires for Polarized Micron-sized Amber Light Emitting Diodes', ACS Photonics, In Press, doi:10.1021/acsphotonics.7b01257 | |
| Type of publication | Article (peer-reviewed) | |
| Link to publisher's version | http://dx.doi.org/10.1021/acsphotonics.7b01257 Access to the full text of the published version may require a subscription. | |
| Rights | © 2018 American Chemical Society. This document is the Accepted Manuscript version of a Published Work that appeared in final form in ACS Photonics, copyright © American Chemical Society after peer review and technical editing by the publisher. To access the final edited and published work see http://pubs.acs.org/doi/abs/10.1021/acsphotonics.7b01257 | |
| Embargo information | Access to this article is restricted until 12 months after publication by request of the publisher. | |
| Embargo lift date | 2019-01-20 | |
| Item downloaded from | http://hdl.handle.net/10468/5357 | |

Downloaded on 2021-11-27T05:16:28Z



Coláiste na hOllscoile Corcaigh





Article

Three-dimensional Self-assembled Columnar Arrays of AllnP Quantum Wires for Polarized Micron-sized Amber Light Emitting Diodes

Andrea Pescaglini, Agnieszka M. Gocalinska, Silviu Bogusevschi, Stefano T. Moroni, Gediminas Juska, Enrica E. Mura, John Justice, Brian Corbet, Eoin O'Reilly, and Emanuele Pelucchi

ACS Photonics, Just Accepted Manuscript • DOI: 10.1021/acsphotonics.7b01257 • Publication Date (Web): 20 Jan 2018 Downloaded from http://pubs.acs.org on January 29, 2018

Just Accepted

"Just Accepted" manuscripts have been peer-reviewed and accepted for publication. They are posted online prior to technical editing, formatting for publication and author proofing. The American Chemical Society provides "Just Accepted" as a free service to the research community to expedite the dissemination of scientific material as soon as possible after acceptance. "Just Accepted" manuscripts appear in full in PDF format accompanied by an HTML abstract. "Just Accepted" manuscripts have been fully peer reviewed, but should not be considered the official version of record. They are accessible to all readers and citable by the Digital Object Identifier (DOI®). "Just Accepted" is an optional service offered to authors. Therefore, the "Just Accepted" Web site may not include all articles that will be published in the journal. After a manuscript is technically edited and formatted, it will be removed from the "Just Accepted" Web site and published as an ASAP article. Note that technical editing may introduce minor changes to the manuscript text and/or graphics which could affect content, and all legal disclaimers and ethical guidelines that apply to the journal pertain. ACS cannot be held responsible for errors or consequences arising from the use of information contained in these "Just Accepted" manuscripts.



ACS Photonics is published by the American Chemical Society. 1155 Sixteenth Street N.W., Washington, DC 20036

Published by American Chemical Society. Copyright © American Chemical Society. However, no copyright claim is made to original U.S. Government works, or works produced by employees of any Commonwealth realm Crown government in the course of their duties.

Three-dimensional Self-assembled Columnar Arrays of AlInP Quantum Wires for Polarized Micron-sized Amber Light Emitting Diodes

Andrea Pescaglini,^a Agnieszka Gocalinska,^{a, *} Silviu Bogusevschi,^{a,b} Stefano T. Moroni,^a Gediminas Juska,^a Enrica E. Mura,^a John Justice,^a Brian Corbett,^a Eoin O'Reilly,^{a,b} Emanuele Pelucchi^a

^a Tyndall National Institute – University College Cork, Lee Maltings, Cork, Ireland

^b Department of Physics, University College Cork, Ireland

KEYWORDS: Self-assembled nanowires, columnar nanowire, yellow LED, polarized LED

A three-dimensional ordered and self-organized semiconductor system emitting highlypolarized light in the yellow-orange visible range (580-650 nm) is presented, comprising selfassembled in-plane AlInP wires vertically stacked in regularly-spaced columns. More than 200 wires per column without detectable defect formation could be stacked. Theoretical simulations and temperature-dependent photoluminescence provided a benchmark to engineer multilayered structures showing internal quantum efficiency at room temperature larger than comparable quantum wells emitting at similar wavelengths. Finally, proof-ofconcept light emitting diodes (LED) showed a high degree of light polarization and lower surface parasitic currents than comparable quantum well LEDs, providing an interesting perspective for high-efficiency polarized yellow-orange light emitting devices.

Light emitting diodes (LEDs) are currently driving innovation in many technological areas, such as displays for TV/monitors, mobiles and laptops, lighting and automotive, optical interconnections, logic and sensing.¹⁻⁴ A key factor for success is the ability to produce light with high efficiency and with a very small footprint, i.e. fundamental properties compatible with the demanding requirements of compactness and integrability. As a consequence, considerable effort has been dedicated to the investigation of novel materials and designs for LED devices, aiming to improve efficiency, spectral properties and to add integrated functionalities.⁵⁻¹⁴

However, some fundamental issues in light emitting diode technology are still outstanding. For instance, semiconductor-based III-V LEDs show a well-known drop in efficiency at wavelengths in the range of 550-640 nm (yellow-red optical band of the spectrum) in both nitride-based and phosphorus-based compounds.¹⁵ In III-P compounds this is linked to poor electron confinement (related to the direct-to-indirect bandgap transition for Al:Ga ratio above ~53:47% in AlGaInP lattice-matched to GaAs,¹⁵ which result in a severe reduction in the radiative recombination efficiency), while in InGaN materials the increasing In content, required to shift the emission from blue towards the vellow, introduces a larger number of structural defects, segregation and strong quantum mechanical Stark effects that seem unavoidable detrimental factors for optical properties.¹⁶⁻¹⁹ Moreover, traditional quantum well LEDs can show a strong reduction in current-to-light conversion efficiency due to nonradiative recombination paths created by surface states (particularly relevant in LEDs in the micron size range), a very relevant limiting factor for truly microLED technology implementation. It should also be added that polarized light emission, critically required in a variety of applications such as LCD screens and environmental lighting,²⁰⁻²² is presently achieved only by additional structures such as gratings, filters and plasmonic nanostructures

ACS Photonics

that increase the complexity of the device fabrication and reduce the external quantum efficiency.²³⁻³⁰

A viable approach able to mitigate these outstanding issues could be the exploitation of carrier confinement in low dimensional nanostructures. For instance, epitaxial growth has been used to self-assemble high density and high crystal quality quantum dots (QDs) providing high temperature stability and low threshold currents in lasers and LEDs.³¹⁻³³ Nevertheless this is a paradigm that critically requires no (defect-related) lattice relaxation. AlGaInP alloys for red emitters do not offer issues in terms of lattice relaxation, as lattice-matching to GaAs can be constantly maintained while varying the Al content to shift the emission from red (650 nm for simple InGaP lattice-matched to GaAs) to yellow, maintaining high crystal quality without any polar crystallographic direction. We observe, on the other hand, that although the quasi 0-dimensionality of QDs allows maximizing the carrier quantum confinement, polarized light for surface emission cannot be directly produced due to a generally high symmetry of the crystallographic structures, as it is also the case in the traditionally exploited quantum wells.

In this regard, the one-dimensionality of wire-like nanostructures would allow the unique coexistence of better carrier confinement and spontaneous polarized emission.³⁴ However, reliable and scalable methods to grow embedded self-assembled wires without pre-patterned templates (such as V-grooves),^{35, 36} and with a design optimized for yellow-orange light emission are, to date, missing.

Here we present a reproducible growth process to realize ordered self-assembled multilayered in-plane AlInP/AlGaInP quantum wires (SMWRs) grown on a GaAs substrate. The wires, with lateral size of \sim 10-25 nm, center-to-center spacing in the growth plane of \sim 50 nm and a few microns in length, can be organized in vertical columns of up to 200 wires per

column, and show light emission in the yellow-orange visible range (580-650 nm). Temperature-dependent photoluminescence spectroscopy alongside a 8-band $\mathbf{k}\cdot\mathbf{p}$ model simulations were exploited to unveil the fundamental physical processes in light production, including the influence of escape processes and band alignments, and to estimate the internal quantum efficiency (IQE).

We also show that the IQE of a 100 layer SMWR structure can be critically improved by adding a quantum well (QW) coupled to the SMWR system (QW-SMWR), functioning as a carrier injector. When compared to a (comparable, but by no means optimized) AlGaInP five QW structure, the IQE of the QW-SMWR hybrid system outperformed the QW structure in the entire range of temperature explored (4-300 K), exhibiting up to one order of magnitude higher internal quantum efficiency (at 100 K). Finally, prototype LED devices were characterized showing low turn-on voltage, lower surface recombination currents compared to QW LEDs and highly polarized in-plane light emission. The results obtained from the QW-SMWR system show great potential in terms of design flexibility and emission efficiency, opening up interesting perspectives towards development of cryogenic and room temperature optoelectronic devices.

All epitaxial samples discussed were grown in a high purity $MOVPE^{37.39}$ commercial horizontal reactor (AIX 200) at low pressure (80 mbar) with purified N₂ as carrier gas. The precursors were trimethylindium (TMIn), trimethylgallium (TMGa), trimethylaluminium (TMAl), diethylzinc (DEZn) arsine (AsH₃), phosphine (PH₃) and disilane (Si₂H₆). The samples' designs consisted in 100 nm Al_{0.75}Ga_{0.25}As, 100 nm (Al_{0.8}Ga_{0.2})_{0.52}In_{0.48}P followed by alternating layers of (Al_{0.6}Ga_{0.4})_{0.52}In_{0.48}P barrier and of Al_xIn_{1-x}P (0.15<x<0.30) with nominal thickness of 3 nm and 0.4 nm respectively. Variation to this design will be described in the text. All growth temperatures (T) quoted have been estimated by emissivity corrected

pyrometry. All samples had a homoepitaxial GaAs 100 nm thick buffer grown prior to the described structure and were capped with 200 nm of $(Al_{0.8}Ga_{0.2})_{0.52}In_{0.48}P$. Growth conditions for the AlGaInP layers were: V/III ratio \sim 630, growth rate \sim 0.4 nm/s; growth conditions for the AlInP layers were: V/III ratio 290, growth rate 0.3 nm/s; samples were grown at growth T of 720 °C on semi-insulating (100) $6^{\circ} \pm 0.02^{\circ}$ off towards [111] A (unless stated otherwise). The LED devices were grown on a n-doped GaAs substrate $6^{\circ} \pm 0.02^{\circ}$ off towards (111) A. structure consisted in 100 nm $Al_{0.75}Ga_{0.25}As:Si$ (n~10¹⁸cm⁻³), 100 nm The $(Al_{0.8}Ga_{0.2})_{0.52}In_{0.48}P$:Si $(n\sim 10^{18} \text{ cm}^{-3})$ followed by alternating layers of $Al_xIn_{1-x}P$ and of (Al_{0.6}Ga_{0.4})_{0.52}In_{0.48}P, as previously described. All samples had a homoepitaxial GaAs:Si $(n\sim10^{18} \text{cm}^{-3})$ 100 nm thick buffer grown prior to the described structure and were finalized with 100 nm of $(Al_{0.8}Ga_{0.2})_{0.52}In_{0.48}P$, 100 nm of $(Al_{0.8}Ga_{0.2})_{0.52}In_{0.48}P$:Zn $(n \sim 10^{18} \text{ cm}^{-3})$, 100 nm AlInP:Zn ($n\sim10^{18}$ cm⁻³), 10 nm InGaP:Zn ($n\sim10^{18}$ cm⁻³) and 10 nm of GaAs:Zn ($n\sim10^{18}$ cm⁻¹) ³). Standard optical lithography, dry-etch and deposition of Ti/Pt/Au (20/30/200 nm) metal contact on the p-side were used to fabricate the LED devices (further details in the Supporting Information (SI)).

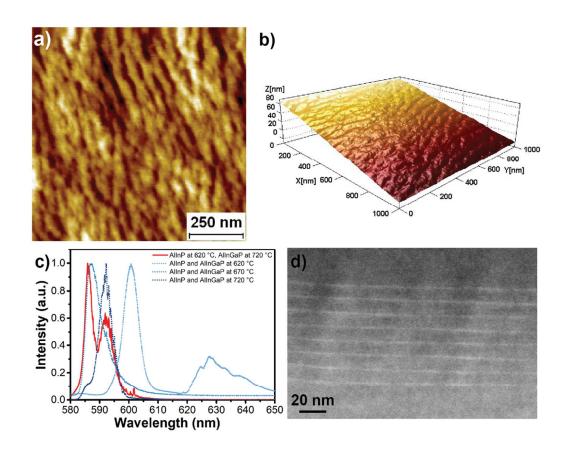


Figure 1: AFM images (a) signal amplitude and (b) reconstructed 3D height image of a single un-capped layer of 0.4 nm (nominal) of $Al_{0.2}In_{0.8}P$ grown on a 6° off GaAs substrate. (c) photoluminescence spectra (at 8K) of single capped $Al_{0.2}In_{0.8}P/(Al_{0.6}Ga_{0.4})_{0.52}In_{0.48}P$ layer grown at 620 (light blue dots), 670 (blue dots), 720 (dark blue dots) °C, respectively, compared to a sample in which $(Al_{0.6}Ga_{0.4})_{0.52}In_{0.48}P$ layers were grown at 720 °C and AlInP layers at 620 °C (red line). (d) Cross-section TEM of a SMWR with 8 $Al_{0.2}In_{0.8}P$ layers separated by 10 nm $(Al_{0.6}Ga_{0.4})_{0.52}In_{0.48}P$ barriers.

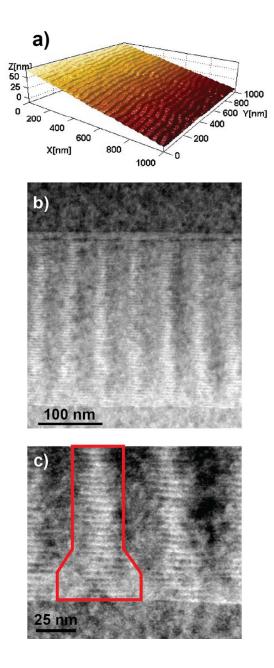
Deposition of lattice-mismatched $Al_xIn_{1-x}P$ (0.15<x<0.30) on $(Al_yGa_{1-y})_{0.52}In_{0.48}P$ (0.3<y<0.90) lattice-matched to GaAs led to spontaneous self-assembled nanostructures via Stranski–Krastanov growth.⁴⁰ Although 3 monolayers (ML) of InP on $(Al_{0.6}Ga_{0.4})_{0.52}In_{0.48}P$ deposited at 620 °C resulted in well-defined semi-spherical dots, typically emitting around ~700 nm (see figure S1 in SI), a significant blue-shifted emission can be achieved by Al

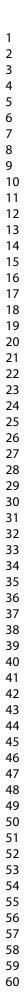
incorporation and reduction of the number of monolayers down to 1-2. Figure 1a-b shows the surface morphology of a single uncapped layer of 0.4 nm (nominal) of $Al_{0.2}In_{0.8}P$ (grown on $(Al_{0.6}Ga_{0.4})_{0.52}In_{0.48}P$) on a 6° off GaAs substrate). The thin layer of material deposited, while developing elongated features on the surface, did not allow to distinguish between quantum dot- or dash-like structures or what could be a simple step bunched surface organization as typically found for MOVPE grown III-V alloys; we note that AlGaInP alloys grown by MOVPE tend to show only very short range surface organization, unlikely their arsenide and InP counterparts.^{38, 41, 42}

Photoluminescence investigations of samples capped with 200 nm of $(Al_{0.6}Ga_{0.4})_{0.52}In_{0.48}P$ showed that the InP "dot-like" emission was shifted towards shorter wavelengths, around 600 nm. Figure 1c shows the PL spectra of three representative samples in which both the $Al_{0.2}In_{0.8}P$ (0.4 nm) and $(Al_{0.6}Ga_{0.4})_{0.52}In_{0.48}P$ layers were grown at the same temperature (620, 670 and 720 °C, respectively) compared to a reference sample where the $Al_{0.2}In_{0.8}P$ layers were grown at 620 °C and the $(Al_{0.6}Ga_{0.4})_{0.52}In_{0.48}P$ layers at 720 °C. The $(Al_{0.6}Ga_{0.4})_{0.52}In_{0.48}P$ emission showed a blue-shift with increasing growth temperature, as expected from the reduction of CuPt ordering⁴³ and also a reduction in intensity, possibly related to closer proximity to the direct-to-indirect bandgap transition. The increasing temperature also resulted in the $Al_{0.2}In_{0.8}P$ emission blue-shifting. The broad peak around 630 nm at 620 °C became a narrow emission around 590 nm, suggesting reduced lateral dimensions and possibly more uniform sizes of the $Al_{0.2}In_{0.8}P$ nanostructures.

The TEM cross section in figure 1d of a multilayer structure including 8 $Al_{0.2}In_{0.8}P/(Al_{0.6}Ga_{0.4})_{0.52}In_{0.48}P$ layers (AlGaInP barriers were 10 nm thick) highlights additional morphological details. The $Al_{0.2}In_{0.8}P$ layer appears to be not homogeneous in thickness, showing a tendency to accumulate in specific areas, with some hints of vertical

coupling of fluctuations, although without a regular organization, either in-plane or out-ofplane. Nevertheless, the PL spectra acquired in samples with $Al_{0.2}In_{0.8}P/(Al_{0.6}Ga_{0.4})_{0.52}In_{0.48}P$ layer numbers (*l*) ranging from 1 to 8 were all comparable in their emission characteristics (within our setup reproducibility), thus excluding significant coupling effects in the AlInP nanostructure morphology and between carrier wavefunctions in different layers (see figure S1 in SI).





ACS Photonics

Figure 2: (a) AFM reconstructed 3D height image of an uncapped SMWR with 20 layers of 0.4 nm (nominal) of $Al_{0.2}In_{0.8}P$ separated by 3 nm (nominal) of $(Al_{0.6}Ga_{0.4})_{0.52}In_{0.48}P$ grown on a 6° off GaAs substrate. The surface appeared to have RMS below 1 nm and height variations in range of few hundreds of picometers along the wire. (b) Cross section TEM of a SMWR with 60 layers, including an $(Al_{0.5}Ga_{0.5})_{0.52}In_{0.48}P$ QW on top of the SMWR (wire direction is perpendicular to the plane). (c) Enlargement of the pedestal of a SMWR column.

The system morphology showed an interesting evolution with increasing number of layers lwhen the $(Al_{0.6}Ga_{0.4})_{0.52}In_{0.48}P$ barrier was decreased down to 3 nm and l increased to more than ~20. The surface morphology of the un-capped sample (figure 2a), where 20 $Al_{0.2}In_{0.8}P$ layers were stacked, and growth finished with the deposition of the last one (without capping layer), indicated the presence of wire-like ordering with length between $0.5-2 \mu m$ and width around 25 nm elongated orthogonally to the substrate tilt direction. The corresponding TEM cross section perpendicular to the wire long axis in figures 2b-c shows a highly ordered system with vertical columns of Al_{0.2}In_{0.8}P wires having a periodicity of around 25 nm. Notably, the self-organization in columns shows a long-range ordering of microns length (along the substrate tilt direction), as demonstrated by the low magnification TEM and SEM pictures showing column arrays without any observable structural defect (see figure S2 in SI). Moreover, focusing at the bottom of each column, one can observe a pedestal-like structure at the beginning of the column formation process. Indeed, the first stacked layers are much more disordered, in agreement with the AFM scan of a single layer, as shown in figure 1a-b. From the cross-section TEM picture, it can be inferred that the system takes around 20 layers in order to self-organize in regular spaced columns arising from the vertical correlation of the in-plane wire formation. We speculate that this organization is fundamentally driven by strain forces related to the large lattice mismatch between the $(Al_{0.6}Ga_{0.4})_{0.52}In_{0.48}P$ layer, which is

lattice-matched to GaAs, and the strained thin $Al_{0.2}In_{0.8}P$ layers.⁴⁰ It is also worth to note that after the required ~20 layers to reach an organized morphology, the resultant system is very stable for a further increase of *l*, allowing growth of samples with up to *l*=200. We also observed that multilayered structures resulted in very different morphologies on perfectly oriented GaAs substrates, and, in general, it was not possible to grow 20 or more layers without the appearance of evident structural relaxation and a resulting red-shift of the emission above 700 nm. Accordingly, we speculate that the surface step (bunched) organization in a 6° off GaAs substrate affects the $Al_{0.2}In_{0.8}P$ ad-atom incorporation and inplane ad-atom mobility and constitutes a key factor for the long-range self-organization of the AlInP wires (see SI).

We finally observe that while the growth organization here seems unique to this material system and has no obvious equivalent in the literature, vertical nanostructure organization has been indeed reported several times in other systems. For early examples see references 44-46.

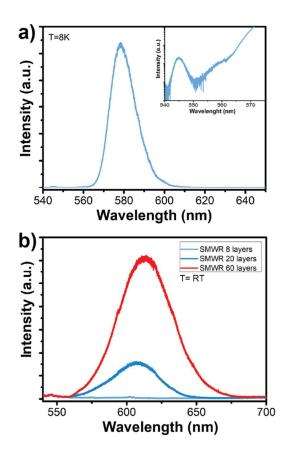


Figure 3: (a) 8 K photoluminescence spectrum of a SMWR with 60 layers, peaked at 580 nm. Insert highlights the weak $(Al_{0.6}Ga_{0.4})_{0.52}In_{0.48}P$ barrier emission around 545 nm. (b) Comparison between the photoluminescence spectra at room temperature of SMWRs with 8 (light blue line), 20 (blue line) and 60 (red line) layers. Notably, the 8 layer SMWR did not show any detectable emission at room temperature.

Figure 3a shows the photoluminescence spectrum at 8 K of a representative sample with l=60. The small peak around 545 nm can reasonably be attributed to the $(Al_{0.6}Ga_{0.4})_{0.52}In_{0.48}P$ barrier emission. The weak intensity of this peak was expected due to the indirect nature of the $(Al_{0.6}Ga_{0.4})_{0.52}In_{0.48}P$ bandgap $((Al_xGa_{1-x})_{0.48}In_{0.52}P$ should show a direct-to-indirect transition at x~0.53). Interestingly, a further increase of the Al content, i.e. further increase of the indirect bandgap, decreased the $Al_{0.2}In_{0.8}P$ wire emission (see figure S3 in SI). Such a photoluminescence quenching was previously reported in AlGaAs and AlGaInP systems and

attributed to an increase of point defects with the Al content in AlGaInP.⁴⁷ On the other hand, the stronger peak at 580 nm, tunable by varying the Al content in the AlInP compound, is attributed to the "wire" emission. Moving from 8 K to room temperature the wire emission was red-shifted by roughly 10-20 nm, comparable to the bandgap renormalization described by the Varshni equation, and dropped by more than 2 orders of magnitude in intensity.

Figure 3b compares the RT emission of three structures having 8, 20 and 60 $Al_{0.2}In_{0.8}P/(Al_{0.4}Ga_{0.6})_{0.52}In_{0.48}P$ layers respectively. Although the SMWR with l=8 did not show any detectable emission at RT, a drastic increase in intensity by at least two orders of magnitudes was observed when *l* was increased from 8 to 20, while a linear trend with the layer number was found for l > 20. This is in agreement with the morphology evolution described in figure 2, in which around 20 periods were required for self-assembled ordering in the columnar nanowires to become established. We also noticed, since the morphology of a multilayer structure with l > 20 was very stable, that the room temperature intensity can be improved by a simple proportional increase of the number *l* (this has been experimentally verified up to l = 200).

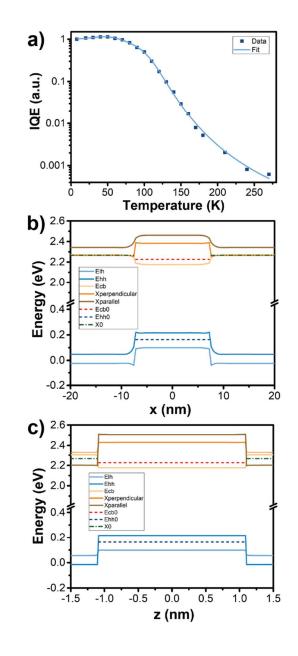


Figure 4: (a) Temperature dependent normalized integrated intensity. Blue line indicates the data fit obtained with eq. 1. (b) Theoretical simulation of the expected band alignment in the growth plane in a 15 nm thick and 2.2 nm tall $Al_{0.2}In_{0.8}P$ wire surrounded by $(Al_{0.6}Ga_{0.4})_{0.52}In_{0.48}P$ at 300 K, plotted along a line through the center of the wire, and perpendicular to the wire axis, and (c) plotted through the center of the wire along the growth direction. The solid lines depict the bulk band edges, and the dashed lines correspond to the ground confined states. The vertical and horizontal separation between wires is 1.2 nm and 25

nm, respectively.

The evolution of the IQE with temperature of a SMWR with *l*=60 is presented in figure 4a. The overall trend expected for an AlGaInP system is a decrease in emission intensity with increasing temperature, attributed to thermally activated escape of excitons from the (poorly) confined regions (wires here, wells in conventional red emitters) to the barriers and to subsequently non-radiative recombination processes.^{47, 48} However, we observe that before the drop in intensity for T>100 K the integrated intensity showed an anomalous increase, reaching its maximum around 50-60 K.⁴⁹ Moreover, a model based on a single escape process was not able to reproduce the data trend above that temperature (see SI).⁴⁸

In order to understand this behavior and get more insights into the system dynamics, we simulated the expected band structure of the $Al_{0.2}In_{0.8}P/(Al_{0.6}Ga_{0.4})_{0.52}In_{0.48}P$ SMWR system (figure 4b-c), using an 8-band **k**·**p** model for the zone-center Γ states, a one-band model for each of the three X states, and ignoring the effects of substrate tilt on the calculated states. Details of the wire structure considered, and of further variations on wire structure are given in SI. The conduction band minimum in the $(Al_{0.6}Ga_{0.4})_{0.52}In_{0.48}P$ barrier is located, as expected, in the X valley. The 2.2% lattice mismatch between the $Al_{0.2}In_{0.8}P$ SMWR and the GaAs substrate results in a strain distribution across the SMWR and the surrounding barrier layers, causing a further reduction of the indirect band gap in the barrier by splitting the X states into X_{\perp} and X_{\parallel} (see SI), where X_{\perp} are the two X states in the growth plane, while X_{\parallel} is the X state along the growth direction. The band alignment for *l*=60 in figure 4b-c shows that the X states in the quantum wires act as a potential barrier, with the lowest X states in the barrier material. For the SMWR structure considered here, the lowest confined X state is in the X_{\perp} valley, although it is possible, e.g. by assuming a wider vertical separation between wires, to have the lowest confined X state in the X_{\parallel} valley. In either case, however, the X

ACS Photonics

states have larger electron effective mass compared to the Γ valley. Assuming the transition of the Γ -like electrons in the quantum wire into the barrier X valley is the likely thermally activated non-radiative pathway in this structure, we find that the potential barrier for direct gap electrons is 10 – 40 meV, depending on exact structure assumed (40 meV in figure 4b-c). On the other hand, heavy holes are confined much deeper in the wire, with the potential barrier between 120 – 195 meV (53 and 178 meV in figure 4b-c respectively to the barrier heavy-hole band edge). Our calculations also show that the variation of wire geometry, which can be seen in figure 2, does not change the (ground state) transition energy significantly enough to reproduce the width of the PL spectra, and it is likely that interdiffusion of Al and Ga occurs between the wire and barrier during growth (see SI).

Building on this analysis, we have used a simple model to describe the temperature dependence of the emission intensity observed in figure 4a. Since the conduction band minimum in AlGaInP is at the X point in reciprocal space, the carrier migration rate from the barriers into the wires is reduced at low temperature, due to the low number of phonons available. However, the electron-phonon scattering probability increases approximately quadratically with temperature, thus allowing excited carriers in the barriers to diffuse into the wires and enhance the wire emission intensity. For temperatures higher than 50-60 K, confined carriers can leak out from the wire. In particular, electrons should be the first to have enough thermal energy to escape, based on the asymmetric carrier confinement energies derived from theory. This process should be followed by a similar thermally activated emission of holes at higher temperatures. If so, the thermally activated migration of carriers from the wire to the barriers and the availability of non-radiative recombination paths outside the wire should be considered the dominant mechanism behind the loss of intensity at room temperature.

According to this, we can estimate the formal behavior of temperature dependency of the integrated intensity I(T) as (see SI)

$$I(T) \propto \frac{1}{1 + \tau_r(T) \left(\frac{1}{\tau_{es}^e(T)} + \frac{1}{\tau_{es}^h(T)} - \frac{1}{\tau_{in}(T)}\right)}$$

where τ_r is the radiative lifetime, τ_{es}^e and τ_{es}^h the escape time constant for electron and holes respectively and τ_{in} the time constant for carrier injection from the barriers to the wires. The variation of the radiative lifetime with temperature can be described as $\tau_r(T) \sim \sqrt{T}$ for a wire $(\tau_r(T) \sim T$ in a well), with $\tau_{es}^{e/h}(T) \sim e^{E_{act}/kT}$ and $\tau_{in}(T) \sim T^{-2}$.^{50, 51}

The data fit showed in figure 4a reproduces well the data across the whole range of temperature. In particular the fit provides ~20 meV and ~120 meV as activation energies for electrons and holes respectively, in reasonable agreement with the theory. It should be noted that according to theoretical predictions electron confinement in $(Al_{0.3}Ga_{0.7})_{0.52}In_{0.48}P$ QWs (emitting at the same wavelength) is expected to be larger, potentially leading to a higher IQE at high temperatures.

Page 17 of 27

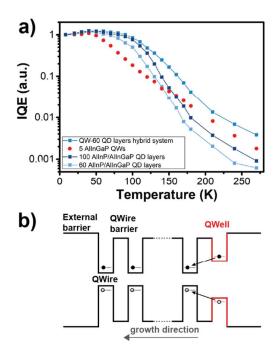
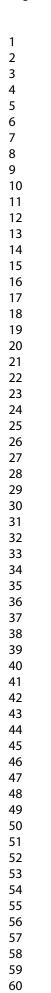


Figure 5: (a) Comparison between the temperature dependent normalized integrated intensities of a SMWR with 60 layers (light blue), a SMWR with 100 layers (blue), a QW-SMWR with 60 layers (dark blue) and a 5 QW $(Al_{0.3}Ga_{0.7})_{0.52}In_{0.48}P/(Al_{0.4}Ga_{0.6})_{0.52}In_{0.48}P$ structure (red). (b) Schematic illustration of the band alignment in the hybrid QW-SMWR system in which the QW is used to inject carriers into the SMWR system.

In order to investigate this aspect, figure 5a compares the temperature-dependent IQE of **SMWRs** with l = 60and l=100,respectively, 5QW and а (Al_{0.3}Ga_{0.7})_{0.52}In_{0.48}P/(Al_{0.4}Ga_{0.6})_{0.52}In_{0.48}P structure emitting at similar wavelength (the number of QWs and their thickness has been designed to sum up to give approximately the same amount of active material deposited as in our wire structures with 100 layers, i.e. with a comparable overall nominal thickness of the emitting layers). We assume the ~ 0 K IQE to be near unity as is custom in these cases. While for T<150 K the SMWR IQE is larger than the that of the QW structure up to 1 order of magnitude (at T=100 K), at RT the QW structure IQE exceeds that of the beats SMWRs by more than a factor of 2.

However, a much larger improvement in the room-temperature efficiency of our structures can be obtained in a hybrid system in which a single quantum well is coupled to the SMWR system. In this scheme of work, depicted in figure 5b, the additional $(Al_{0.5}Ga_{0.5})_{0.52}In_{0.48}P$ quantum well, having a bandgap slightly larger than the wires (i.e. not contributing to the wire emission photoluminescence), can be used as a reservoir to inject carriers into the wires, and partially compensate the thermally activated quenching of the emission.⁵² The IQE of the resultant hybrid device, containing just 60 layers (just over half that of the SMWRs shown by the dark blue dots in figure 5a), showed more than one order of magnitude higher efficiency compared to the system without a QW, and exceeds the efficiency of the 5QW $(Al_{0.3}Ga_{0.7})_{0.52}In_{0.48}P/(Al_{0.6}Ga_{0.4})_{0.52}In_{0.48}P$ structure over the full temperature range. We also noticed that a minor improvement in the overall efficiency was obtained by increasing Al content in AlGaInP barriers before and after the multilayer structure from $(Al_{0.6}Ga_{0.2})_{0.52}In_{0.48}P$ to $(Al_{0.8}Ga_{0.2})_{0.52}In_{0.48}P$ and by adding some strain to these barriers (see SI). This result demonstrates that the SMWR structure can be engineered not only to achieve a specific target wavelength, but also to improve red emitter efficiency by structural design.



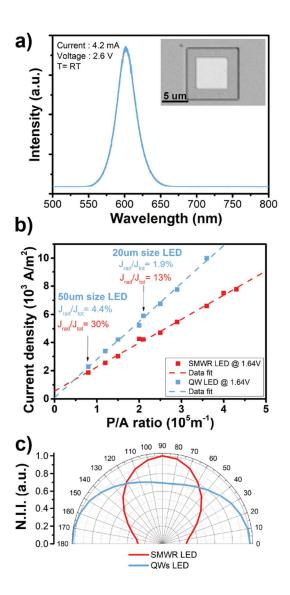


Figure 6: (a) Electroluminescence spectrum of a representative SMWR LED. Inset shows an optical image of the measured device. (b) Plot of current density versus Perimeter/Area (P/A) ratio, demonstrating a larger contribution of the surface current to the total current in a 5QW (Al_{0.3}Ga_{0.7})_{0.52}In_{0.48}P/(Al_{0.6}Ga_{0.4})_{0.52}In_{0.48}P LED then in a SMWR LED. No significant spectral shift was observed in these current intervals (c) A normalized polar plot of the integrated intensity of linearly polarized light as a function of analyzer's angle. The light was collected from top-view from both LED devices.

To test the feasibility of higher efficiency light emitting electrical devices, a prototype SMWR microLED device (structure details in SI), was compared to a similarly processed 5QW ($Al_{0.3}Ga_{0.7}$)_{0.52}In_{0.48}P/($Al_{0.6}Ga_{0.4}$)_{0.52}In_{0.48}P LED. A representative electroluminescence spectrum of a SMWR LED device indicated an optical emission peaked at 610 nm (at room temperature), in agreement with the photoluminescence spectrum of the equivalent SMWR structure and showed a turn on voltage of ~1.6 V corresponding to a current density of ~0.1 A/cm². Similar values were observed for the QW LED, indicating that the low current density required should be ascribed to the current-spreading layer design rather than the material structure. Investigation of LED devices with comparable surface area but different perimeters unveiled important differences in the surface current contribution for the two types of LEDs. In a first approximation, the total current density injected into the LED can be described by⁵³

$$J_{TOT} = J_{bulk} + \sigma_{surf} \frac{P}{A}$$

where J_{bulk} is the current density flowing through the bulk of the material, σ_{surf} (A/m) the surface current per unit length of perimeter P and A the area of the LED, respectively. Assuming that the carriers flowing through the surface do not recombine radiatively, and the emission intensity is only proportional to J_{bulk} , the percentage of the injected current J_{bulk}/J_{TOT} that contributes to the radiative emission can be inferred from the linear fit of the data. In particular, two different trends for the QWs and the SMWRs LEDs were observed. In both devices only a small fraction of the injected current was actually passing through the bulk of the material. In the 50x50 μ m² QW LED only 4.4 % of the total current is contributing to the emission, with this value decreasing to 1.9 % in a 20x20 μ m² device. On

ACS Photonics

the other hand, the value of J_{bulk}/J_{TOT} in the SMWR LED was found to be 30 % and 13 % for the 50x50 µm² and 20x20 µm² device, respectively, almost one order of magnitude larger. The reduction of the surface leakage current was further supported by a reduction in the current spreading (see SI) in the SMWR LED. In fact, the higher degree of space confinement and potential fluctuations experienced by carriers in the wires, compared to that in the QWs, reduces the carrier diffusion towards the LED surface before recombination. This therefore suggests that higher current-to-light conversion efficiency and a LED size reduction without any loss in efficiency are achievable in QW-SMWRs.

An important additional benefit of SMWR LEDs is that their spontaneous light emission is polarized predominantly along the wire main axis. Figure 6c shows the normalized integrated intensity (NII) of linearly polarized light (filtered for polarization as described in SI) versus the sample rotation angle for the SMWR and QW LEDs. The QW LED showed only a weak sign (around 30 %, for definition see SI) of polarization along the substrate tilt direction, indicating that the tilted GaAs substrate might affect the QW morphology or introduce residual strain, resulting in a low degree of polarization. On the other hand, the wires possessed strong emission anisotropy, with almost 80 % of the emitted light polarized along the wire main axis, i.e. perpendicular to the substrate tilt direction, making them extremely interesting for modern display/augmented reality (and similar) applications. It should be noted also that the presence of a large metal contact covering more than 50 % of the LED top surface reduced the amount of direct light that could be collected by the optical setup; therefore we expect that the degree of polarization could have been reduced in our measurements by scattered light from the sidewalls of the LED.

In conclusion, we presented a novel multilayer structure comprising self-assembled columns of AlInP wires with tunable emission between 580 and 650 nm. The growth

condition and morphology was investigated and optimized, resulting in a reliable method to growth a large number of Al_{0.2}In_{0.8}P/(Al_{0.6}Ga_{0.4})_{0.52}In_{0.48}P layers at high temperature (720 °C). The structure design was engineered to maximize the efficiency by optimizing AlInP and AlGaInP layer thicknesses, growth temperatures and Al content in the barriers. A qualitative physical model based on theoretical simulations was proposed and demonstrated capable to describe satisfactorily the SMWR temperature-dependent photoluminescence. The IQE was investigated and compared to a 5QW AlGaInP sample and to a QW-SMWR sample, demonstrating that adding a QW coupled to the SMWR system boosts by more than one order of magnitude the IQE, outperforming the AlGaInP QWs. Finally, investigation of the QW-SMWR microLED prototype indicated further advantages over the traditional QW LED in the reduced surface parasitic current and in the emission of strongly polarized light.

These results provide an interesting perspective for SMWR structures for polarized highefficiency yellow/amber/red light emitting diodes.

AUTHOR INFORMATION

Corresponding Author

*agnieszka.gocalinska@tyndall.ie

Author Contributions

The manuscript was written through contributions of all authors. All authors have given approval to the final version of the manuscript.

| 1 2 | |
|--|--|
| 2 3 4 | |
| 5 | |
| 6 7 8 | |
| 8 9 10 | |
| 10 11 | |
| 12 13 | |
| 14 15 | |
| 16 17 | |
| 18 19 | |
| 20 21 | |
| 22 | |
| 11 12 13 14 15 16 17 18 19 20 21 22 23 24 25 26 27 28 | |
| 25 | |
| 27 28 | |
| 20 29 30 | |
| 30 31 32 33 34 35 36 | |
| 33 34 | |
| 35 36 | |
| 37 38 | |
| 39 40 | |
| 40 41 42 | |
| 43 | |
| 44 45 | |
| 46 47 | |
| 48 49 | |
| 50 51 | |
| 52 53 | |
| 55 54 55 | |
| 56 | |
| 57 58 | |
| 59 60 | |

SUPPORTING INFORMATION

Additional details and Supplementary Figures S1-S6.

ACKNOWLEDGMENT

This research was enabled by Science Foundation Ireland under the IPIC award 12/RC/2276,

grant 10/IN.1/I3000, 15/IA/2864 and the Irish Research Council under grant EPSPG/2014/35.

We thank Kevin Thomas for the MOVPE support.

REFERENCES

1. Ross, J. S.; Klement, P.; Jones, A. M.; Ghimire, N. J.; Yan, J.; Mandrus, D. G.; Taniguchi, T.; Watanabe, K.; Kitamura, K.; Yao, W.; Cobden, D. H.; Xu, X. Electrically Tunable Excitonic Light-Emitting Diodes Based on Monolayer WSe₂ P-N Junctions, *Nat Nano* **2014**, 9, (4), 268-272.

2. Xia, F.; Steiner, M.; Lin, Y.-M.; Avouris, P. A Microcavity-Controlled, Current-Driven, On-Chip Nanotube Emitter at Infrared Wavelengths. *Nat Nano* **2008**, 3, (10), 609-613.

3. Supran, G. J.; Shirasaki, Y.; Song, K. W.; Caruge, J.-M.; Kazlas, P. T.; Coe-Sullivan, S.; Andrew, T. L.; Bawendi, M. G.; Bulović, V. QLEDs for Displays and Solid-State Lighting. *MRS Bulletin* **2013**, 38, (9), 703-711.

4. Baugher, B. W. H.; Churchill, H. O. H.; Yang, Y.; Jarillo-Herrero, P. Optoelectronic Devices Based on Electrically Tunable P-N Diodes in a Monolayer Dichalcogenide. *Nat Nano* **2014**, *9*, (4), 262-267.

5. Dai, X.; Zhang, Z.; Jin, Y.; Niu, Y.; Cao, H.; Liang, X.; Chen, L.; Wang, J.; Peng, X. Solution-Processed, High-Performance Light-Emitting Diodes Based on Quantum Dots. *Nature* **2014**, 515, (7525), 96-99.

6. Shirasaki, Y.; Supran, G. J.; Bawendi, M. G.; Bulovic, V. Emergence of Colloidal Quantum-Dot Light-Emitting Technologies. *Nat Photon* **2013**, *7*, (1), 13-23.

7. Nakanotani, H.; Higuchi, T.; Furukawa, T.; Masui, K.; Morimoto, K.; Numata, M.; Tanaka, H.; Sagara, Y.; Yasuda, T.; Adachi, C. High-Efficiency Organic Light-Emitting Diodes with Fluorescent Emitters. *Nature Communications* **2014**, *5*, 4016.

8. Essig, S.; Marquardt, C. W.; Vijayaraghavan, A.; Ganzhorn, M.; Dehm, S.; Hennrich, F.; Ou, F.; Green, A. A.; Sciascia, C.; Bonaccorso, F.; Bohnen, K. P.; Löhneysen, H. V.; Kappes, M. M.; Ajayan, P. M.; Hersam, M. C.; Ferrari, A. C.; Krupke, R. Phonon-Assisted Electroluminescence from Metallic Carbon Nanotubes and Graphene. *Nano Lett.* **2010**, 10, (5), 1589-1594.

9. Withers, F.; Del Pozo-Zamudio, O.; Mishchenko, A.; Rooney, A. P.; Gholinia, A.; Watanabe, K.; Taniguchi, T.; Haigh, S. J.; Geim, A. K.; Tartakovskii, A. I.; Novoselov, K. S. Light-Emitting Diodes by Band-Structure Engineering in van der Waals Heterostructures. *Nat. Mater.* **2015**, 14, (3), 301-306.

10. Kim, S.-Y.; Jeong, W.-I.; Mayr, C.; Park, Y.-S.; Kim, K.-H.; Lee, J.-H.; Moon, C.-K.; Brütting, W.; Kim, J.-J. Organic Light-Emitting Diodes with 30% External Quantum

3

4 5

6

7

8

9

10

11

12

13

14

15

16

17

18 19

20

21

22

23

24

25

26

27

28

29

30

31 32

33

34

35

36

37

38

39

40

41

42

43

44

45

46

47

48

49

50

51

52

53

54

55

60

Efficiency Based on a Horizontally Oriented Emitter, Adv. Funct. Mater. 2013, 23, (31), 3896-3900. 11. Pust, P.; Weiler, V.; Hecht, C.; Tücks, A.; Wochnik, A. S.; Henß, A.-K.; Wiechert, D.; Scheu, C.; Schmidt, P. J.; Schnick, W. Narrow-Band Red-Emitting Sr[LiAl₃N₄]:Eu²⁺ as a Next-Generation LED-Phosphor Material. Nat. Mater. 2014, 13, (9), 891-896. Choi, M. K.; Yang, J.; Kang, K.; Kim, D. C.; Choi, C.; Park, C.; Kim, S. J.; Chae, S. 12. I.; Kim, T.-H.; Kim, J. H.; Hyeon, T.; Kim, D.-H. Wearable Red–Green–Blue Quantum Dot Light-Emitting Diode Array Using High-Resolution Intaglio Transfer Printing. Nature Communications 2015, 6, 7149. 13. Oh, N.; Kim, B. H.; Cho, S.-Y.; Nam, S.; Rogers, S. P.; Jiang, Y.; Flanagan, J. C.; Zhai, Y.; Kim, J.-H.; Lee, J.; Yu, Y.; Cho, Y. K.; Hur, G.; Zhang, J.; Trefonas, P.; Rogers, J. A.; Shim, M. Double-Heterojunction Nanorod Light-Responsive LEDs for Display Applications. Science 2017, 355, (6325), 616-619. Chung, K.; Sui, J.; Demory, B.; Teng, C.-H.; Ku, P.-C. Monolithic Integration of 14. Individually Addressable Light-Emitting Diode Color Pixels. Appl. Phys. Lett. 2017, 110, (11), 111103.15. Krames, M. R.; Shchekin, O. B.; Mueller-Mach, R.; Mueller, G.; Zhou, L.; Harbers, G.; Craford, M. G. Status and Future of High-Power Light-Emitting Diodes for Solid-State Lighting. Journal of Display Technology 2007, 3, (2), 160-175. Kim, M.-H.; Schubert, M. F.; Dai, O.; Kim, J. K.; Schubert, E. F.; Piprek, J.; Park, Y. 16. Origin of Efficiency Droop in GaN-Based Light-Emitting Diodes. Appl. Phys. Lett. 2007, 91, (18), 183507. Kioupakis, E.; Rinke, P.; Delaney, K. T.; Walle, C. G. V. d. Indirect Auger 17. Recombination as a Cause of Efficiency Droop in Nitride Light-Emitting Diodes. Appl. Phys. Lett. 2011, 98, (16), 161107. Pust, P.; Schmidt, P. J.; Schnick, W. A Revolution in Lighting. Nat. Mater. 2015, 14, 18. (5), 454-458.19. Verzellesi, G.; Saguatti, D.; Meneghini, M.; Bertazzi, F.; Goano, M.; Meneghesso, G.; Zanoni, E. J. Efficiency Droop in InGaN/GaN Blue Light-Emitting Diodes: Physical Mechanisms and Remedies. Appl. Phys. 2013, 114, (7), 071101. Japuntich, D. A. Polarized Task Lighting to Reduce Reflective Glare in Open-Plan 20. Office Cubicles. Applied Ergonomics 2001, 32, (5), 485-499. Chien, K.-W.; Shieh, H.-P. D. Design and Fabrication of an Integrated Polarized 21. Light Guide for Liquid-Crystal-Display Illumination. Appl. Opt. 2004, 43, (9), 1830-1834. Matioli, E.; Brinkley, S.; Kelchner, K. M.; Hu, Y.-L.; Nakamura, S.; DenBaars, S.; 22. Speck, J.; Weisbuch, C. High-Brightness Polarized Light-Emitting Diodes. Light Sci Appl **2012.** 1, e22. 23. Chien, K.-W.; Shieh, H.-P. D.; Cornelissen, H. Polarized Backlight Based on Selective Total Internal Reflection at Microgrooves. Appl. Opt. 2004, 43, (24), 4672-4676. Gardner, N. F.; Kim, J. C.; Wierer, J. J.; Shen, Y. C.; Krames, M. R. Polarization 24. Anisotropy in the Electroluminescence of *m*-Plane InGaN-GaN Multiple-Quantum-Well Light-Emitting Diodes. Appl. Phys. Lett. 2005, 86, (11), 111101. 25. Greger, E.; Gulden, K. H.; Riel, P.; Schweizer, H. P.; Moser, M.; Schmiedel, G.; Kiesel, P.; Döhler, G. H. Polarization Effect in Light Emitting Diodes With Ordered GaInP Active Layers. Appl. Phys. Lett. 1996, 68, (17), 2383-2385. Ma, M.; Meyaard, D. S.; Shan, Q.; Cho, J.; Schubert, E. F.; Kim, G. B.; Kim, M.-H.; 26. Sone, C. Polarized Light Emission from GaInN Light-Emitting Diodes Embedded with Subwavelength Aluminum Wire-Grid Polarizers. Appl. Phys. Lett. 2012, 101, (6), 061103. Köck, A.; Gornik, E.; Hauser, M.; Beinstingl, W. Strongly Directional Emission from 27. AlGaAs/GaAs Light-Emitting Diodes. Appl. Phys. Lett. 1990, 57, (22), 2327-2329.

ACS Photonics

| 28. Lozano, G.; Louwers, D. J.; Rodriguez, S. R. K.; Murai, S.; Jansen, O. T. A.; Verschuuren, M. A.; Gomez Rivas, J. Plasmonics for Solid-State Lighting: Enhanced Excitation and Directional Emission of Highly Efficient Light Sources. <i>Light Sci Appl</i> 2013 , 2, e66. |
|--|
| 29. Ren, M.; Chen, M.; Wu, W.; Zhang, L.; Liu, J.; Pi, B.; Zhang, X.; Li, Q.; Fan, S.; Xu, J. Linearly Polarized Light Emission from Quantum Dots with Plasmonic Nanoantenna Arrays. <i>Nano Lett.</i> 2015, 15, (5), 2951-2957. |
| 30. Schubert, M. F.; Chhajed, S.; Kim, J. K.; Schubert, E. F.; Cho, J. Linearly Polarized Emission from GaInN Light-Emitting Diodes with Polarization-Enhancing Reflector. <i>Optics Express</i> 2007 , 15, (18), 11213-11218. |
| 31. Schulz, WM.; Eichfelder, M.; Roßbach, R.; Jetter, M.; Michler, P. Low Threshold InP/AlGaInP Quantum Dot In-Plane Laser Emitting at 638 nm. <i>Applied Physics Express</i> 2009 , 2, (11), 112501. |
| 32. Roßbach, R.; Schulz, W. M.; Eichfelder, M.; Reischle, M.; Beirne, G. J.; Jetter, M.; Michler, P. Red to Orange Electroluminescence from InP/AlGaInP Quantum Dots at Room Temperature. <i>J. Cryst. Growth</i> 2008 , 310, (23), 5098-5101. |
| 33. Schulz, W. M.; Roßbach, R.; Reischle, M.; Beirne, G. J.; Bommer, M.; Jetter, M.; Michler, P. Optical and Structural Properties of InP Quantum Dots Embedded in $(Al_xGa_{1-x})_{0.51}In_{0.49}P.$ <i>Phys. Rev. B</i> 2009 , 79, (3), 035329. |
| 34. Pearah, P. J.; Stellini, E. M.; Chen, A. C.; Moy, A. M.; Hsieh, K. C.; Cheng, K. Y. Strained Ga _x In _{1-x} P Multiple Quantum Wire Light-Emitting Diodes: A Luminescence Polarization Study. <i>Appl. Phys. Lett.</i> 1993 , 62, (7), 729-731. |
| 35. Simhony, S.; Kapon, E.; Colas, E.; Hwang, D.; Stoffel, N.; Worland, P. Vertically Stacked Multiple-Quantum-Wire Semiconductor Diode Lasers. <i>Appl. Phys. Lett.</i> 1991 , 59, (18), 2225-2227. |
| 36. Tsukamoto, S.; Nagamune, Y.; Nishioka, M.; Arakawa, Y. Fabrication of GaAs Quantum Wires on Epitaxially Grown V Grooves by Metal-Organic Chemical-Vapor Deposition. <i>J. Appl. Phys.</i> 1992 , <i>71</i> , (1), 533-535. |
| 37. Dimastrodonato, V.; Mereni, L. O.; Young, R. J.; Pelucchi, E. AlGaAs/GaAs/AlGaAs Quantum Wells as a Sensitive Tool for the MOVPE Reactor Environment. <i>J. Cryst. Growth</i> 2010 , 312, (21), 3057-3062. |
| 38. Pelucchi, E.; Moret, N.; Dwir, B.; Oberli, D. Y.; Rudra, A.; Gogneau, N.; Kumar, A.; Kapon, E.; Levy, E.; Palevski, A. Sub-meV Photoluminescence Linewidth and >10 ⁶ cm ² /Vs Electron Mobility in AlGaAs/GaAsAlGaAs/GaAs Quantum Wells Grown by Metalorganic Vapor Phase Epitaxy on Slightly Misoriented Substrates. <i>J. Appl. Phys.</i> 2006 , 99, (9), 093515. |
| 39. Young, R. J.; Mereni, L. O.; Petkov, N.; Knight, G. R.; Dimastrodonato, V.; Hurley, P. K.; Hughes, G.; Pelucchi, E. Low-Angle Misorientation Dependence of the Optical Properties of InGaAs/InAlAs Quantum Wells. <i>J. Cryst. Growth</i> 2010, 312, (9), 1546-1550. 40. Nötzel, R. Self-Organized Growth of Quantum-Dot Structures. <i>Semicond. Sci.</i> |
| Technol. 1996, 11, (10), 1365. 41. Chua, A. LS.; Pelucchi, E.; Rudra, A.; Dwir, B.; Kapon, E.; Zangwill, A.; Vvedensky, D. D. Theory and Experiment of Step Bunching on Misoriented GaAs (001) During Metalorganic Vapor-Phase Epitaxy. <i>Appl. Phys. Lett.</i> 2008, 92, (1), 013117. 42. Gocalinska, A.; Manganaro, M.; Pelucchi, E.; Vvedensky, D. D. Surface Organization of Homoepitaxial InP Films Grown by Metalorganic Vapor-Phase Epitaxy. <i>Phys. Rev. B</i> 2012, 86, (16), 165307. |
| 43. Halsall, M. P.; Dunbar, A. D. F.; Bangert, U. Electron Diffraction and Raman Studies of the Effect of Substrate Misorientation on Ordering in the AlGaInP System. <i>J. Appl. Phys.</i> 1999, 85, (1), 199-202. |
| |
| ACS Paragon Plus Environment |

44. Teichert, C.; Lagally, M. G.; Peticolas, L. J.; Bean, J. C.; Tersoff, J. Stress-Induced Self-Organization of Nanoscale Structures in SiGe/Si Multilayer Films. *Phys. Rev. B* **1996**, 53, (24), 16334-16337.

45. Tersoff, J.; Teichert, C.; Lagally, M. G. Self-Organization in Growth of Quantum Dot Superlattices. *Phys. Rev. Lett.* **1996**, 76, (10), 1675-1678.

46. He, J.; Krenner, H. J.; Pryor, C.; Zhang, J. P.; Wu, Y.; Allen, D. G.; Morris, C. M.; Sherwin, M. S.; Petroff, P. M. Growth, Structural, and Optical Properties of Self-Assembled (In,Ga)As Quantum Posts on GaAs. *Nano Lett.* **2007**, *7*, (3), 802-806.

47. Lambkin, J. D.; Dunstan, D. J.; Homewood, K. P.; Howard, L. K.; Emeny, M. T. Thermal Quenching of the Photoluminescence of InGaAs/GaAs and InGaAs/AlGaAs Strained-Layer Quantum Wells. *Appl. Phys. Lett.* **1990**, *57*, (19), 1986-1988.

48. Daly, E. M.; Glynn, T. J.; Lambkin, J. D.; Considine, L.; Walsh, S. Behavior of In_{0.48}Ga_{0.52}P/(Al_{0.2}Ga_{0.8})_{0.52}In_{0.48}P Quantum-Well Luminescence as a Function of Temperature. *Phys. Rev. B* **1995**, 52, (7), 4696-4699.

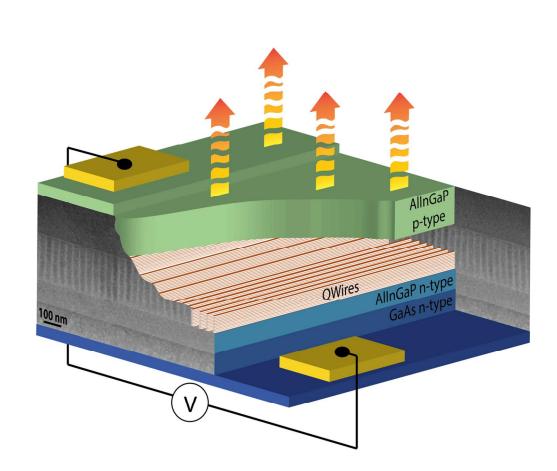
49. Fang, Y.; Wang, L.; Sun, Q.; Lu, T.; Deng, Z.; Ma, Z.; Jiang, Y.; Jia, H.; Wang, W.; Zhou, J.; Chen, H. Investigation of Temperature-Dependent Photoluminescence in Multi-Quantum Wells. *Scientific Reports* **2015**, *5*, 12718.

50. Akiyama, H.; Koshiba, S.; Someya, T.; Wada, K.; Noge, H.; Nakamura, Y.; Inoshita, T.; Shimizu, A.; Sakaki, H. Thermalization Effect on Radiative Decay of Excitons in Quantum Wires. *Phys. Rev. Lett.* **1994**, 72, (6), 924-927.

51. Giazotto, F.; Heikkilä, T. T.; Luukanen, A.; Savin, A. M.; Pekola, J. P. Opportunities for Mesoscopics in Thermometry and Refrigeration: Physics and Applications. *Reviews of Modern Physics* **2006**, 78, (1), 217-274.

52. Jin, C. Y.; Ohta, S.; Hopkinson, M.; Kojima, O.; Kita, T.; Wada, O. Temperature-Dependent Carrier Tunneling for Self-Assembled InAs/GaAs Quantum Dots with a GaAsN Quantum Well Injector. *Appl. Phys. Lett.* **2010**, 96, (15), 151104.

53. Tanriseven, S.; Corbett, B. Low Effective Surface Recombination in In(Ga)As/GaAs Quantum Dot Dxiodes. *J. Appl. Phys.* **2011**, 110, 034508.



TOC Graphics 230x190mm (150 x 150 DPI)